Process Development, Monitoring, Modeling, and Control for Biogas Cleaning

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Deadline for manuscript submissions:
closed (30 May 2021)

Message from the Guest Editors

This Special Issue on "Process Development, Monitoring, Modeling, and Control for Biogas Cleaning" will collect high-quality research that addresses challenges in the broad area of biogas cleaning, process modeling, and control strategies. Topics include but are not limited to the following:

- Biotrickling filters (aerobic and anoxic);
- Suspended biomass bioreactors (aerobic and anoxic);
- Chemical absorption;
- Physical and chemical adsorption on solid adsorbents;
- Solvent-gas scrubbing;
- Membrane separation;
- Cryogenic separation;
- Process modeling, simulation, and control applications.

Special Issue

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Message from the Editor-in-Chief

Processes (ISSN 2227-9717) provides an advanced forum
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